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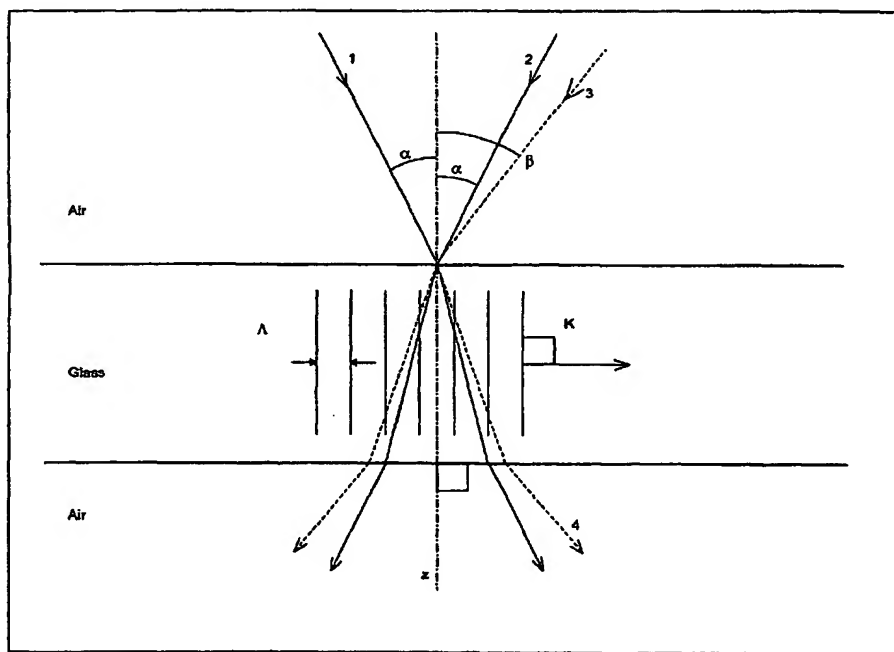
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(54) Title: **PHOTOSENSITIVE MATERIAL AND PROCESS OF MAKING SAME**



(57) Abstract: A photosensitive material, suitable for image-wise recording, e.g., holographic recording of data or other information, comprises an organic species in an organic-inorganic matrix, the organic species comprising a material having a refractive index which changes upon exposure to actinic radiation. The organic-inorganic matrix may be an organically modified glass. The photo-sensitive material may be made using the sol-gel process.

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